

**IN THE SPECIFICATION:**

Please replace the paragraph beginning at page 4, line 12 with the following:

It is preferable that a base film comprises at least one film layer having a gas transmission rate of not more than  $1.0 \text{ cc/m}^2\cdot\text{day}\cdot\text{atm}$  and water absorptance of not more than 1.0 weight %. This is because out-gas from the adhesive film can be reduced and the time taken to reach ~~initia~~ initial (blank) vacuum level can be shortened in a process for forming a metal film. By using the adhesive film according to the present invention, damage to the non-metal-film-formed surface can be suppressed when forming a metal film and productivity can be enhanced. Furthermore, since contamination on the non-metal-film-formed surface can be suppressed, a step of washing with a solvent can be omitted, and thus improvement in workability can also be achieved.